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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/208,105	11/25/1998	KAZUHISA SAKAMOTO	10233.81USW1	7685	
7:	590 04/25/2003			**	
CURTIS B. HAMRE			EXAMINER		
MERCHANT & GOULD P.O. BOX 2903			NADAV, ORI		
MINNEAPOLI	S, MN 55402-2903		ART UNIT	PAPER NUMBER	
*		·	2811		

DATE MAILED: 04/25/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application	No.	Applicant(s)	
9 Office Action Summary					,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,
		09/208,105		SAKAMOTO, KAZUHISA /	
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Period fo		pears on are co	over sneet wan are e	orrespondence ad	ure33
THE - External control	MAILING DATE OF THIS COMMUNICATION. ensions of time may be available under the provisions of 37 CFR 1. r SIX (6) MONTHS from the mailing date of this communication. e period for reply specified above is less than thirty (30) days, a reploperiod for reply is specified above, the maximum statutory period ure to reply within the set or extended period for reply will, by statut reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).		however, may a reply be tim y minimum of thirty (30) day: pire SIX (6) MONTHS from ion to become ABANDONE	nely filed s will be considered timely the mailing date of this co D (35 U.S.C. § 133).	
1)🛛	Responsive to communication(s) filed on 06	<u>March 2003</u> .			
2a)∟]	This action is FINAL . 2b) \(\sum \)	his action is no	n-final.		
3)	• •				e merits is
Disposit	closed in accordance with the practice under ion of Claims	i Ex parie Qua _.	ую, 1935 С.D. 11, 4	53 O.G. 213.	
4)🛛	Claim(s) 9-14 is/are pending in the applicatio	n.			
	4a) Of the above claim(s) is/are withdra	awn from consi	deration.		
5)	Claim(s) is/are allowed.				
6)⊠	Claim(s) <u>9-14</u> is/are rejected.				
7)	Claim(s) is/are objected to.				
	Claim(s) are subject to restriction and/o	or election requ	uirement.		
	ion Papers				
	The specification is objected to by the Examine		- 6 - 5		
الكا(10	i he drawing(s) filed on 25 November 1998 is/a				
11\□	Applicant may not request that any objection to the The proposed drawing correction filed on		*	· /	
لسارانا	If approved, corrected drawings are required in re		oved b) disappro	ved by the Examine	31.
12)	The oath or declaration is objected to by the E		, action.		
-	under 35 U.S.C. §§ 119 and 120				
_	Acknowledgment is made of a claim for foreig	ın priority unde	r 35 U.S.C. § 119(a)-(d) or (f)	
•	□ All b)□ Some * c)□ None of:	, p		, (4) 5. (.).	
,	1. Certified copies of the priority documen	nts have been r	eceived.		
	2. Certified copies of the priority documen	•		on No	
* (3. Copies of the certified copies of the price application from the International Buse the attached detailed Office action for a list.	ority document ureau (PCT Ru	s have been receive le 17.2(a)).	ed in this National	Stage
14) 🔲 🗸	Acknowledgment is made of a claim for domes	tic priority unde	er 35 U.S.C. § 119(e	e) (to a provisional	application).
	a) The translation of the foreign language pr Acknowledgment is made of a claim for domes				
Attachmer	nt(s)				
2) Notice	ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449) Paper No(s)	5)		(PTO-413) Paper No(Patent Application (PT	

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DETAILED ACTION

Drawings

The drawings are objected to because figure î depicts crystal defects 11 located only under central opening 25, and not under the openings located on adjacent sides thereof. A proposed drawing correction or corrected drawings are required in reply to the Office action to avoid abandonment of the application. The objection to the drawings will not be held in abeyance.

Specification

2. The disclosure is objected to because of the following informalities: Figure 1 depicts crystal defects 13. However, crystal defects 13 are not mentioned in the description of the embodiment of figure 1.

Appropriate correction is required.

Claim Rejections - 35 USC § 112

3. The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

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4. Claims 9-14 are rejected under 35 U.S.C. 112, first paragraph, as containing subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention. The specification describes radiating rays passing through the opening and generate crystal defects under the opening and laterally adjacent to the opening (see figure 1). Therefore, there is no support for radiating rays passing to the region irradiated through the opening and generating crystal defects only under the opening, as recited in claim 9.

5. There is no support for a metal wiring layer having a thickness so as to restrict penetration of rays into the region irradiated, as recited in claim 10, because the metal wiring layer does not restrict penetration of rays into the region irradiated and does not restrict penetration of rays into regions adjacent to region irradiated.

Claim Rejections - 35 USC § 102

6. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371© of this title before the invention thereof by the applicant for patent.

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The changes made to 35 U.S.C. 102(e) by the American Inventors

Protection Act of 1999 (AIPA) do not apply to the examination of this application as the application being examined was not (1) filed on or after November 29, 2000, or (2) voluntarily published under 35 U.S.C. 122(b). Therefore, this application is examined under 35 U.S.C. 102(e) prior to the amendment by the AIPA (pre-AIPA 35 U.S.C. 102(e)).

7. Claims 9 and 11-12, insofar as in compliance with 35 U.S.C. 112, are rejected under 35 U.S.C. 102(e) as being anticipated by Sakamoto (5,808,352).

Sakamoto teaches in figure 1 and related text a semiconductor device comprising a substrate 10, 11 having a region 11 irradiated with radiating rays, crystal defects 21 within the region irradiated, impurity regions 12, 13 in the substrate, and a light metal wiring layer 18, 19 comprising aluminum located over the substrate and being connected to each of the impurity regions and having an opening above the region irradiated so that radiating rays passing to the region irradiated through the opening generate crystal defects only under the opening.

Regarding claims 11 and 12, Sakamoto teaches in figures 1 an insulation layer being formed above the region irradiated, the opening being on the insulating layer, and the metal wiring 18, 19 covers part of the insulating layer.

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Claim Rejections - 35 USC § 103

- 8. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which the subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- Claim 10, insofar as in compliance with 35 U.S.C. 112, is rejected under 35
 U.S.C. 103(a) as being unpatentable over Sakamoto.

Sakamoto teaches substantially the entire claimed structure, as applied to claim 9 above, except a metal wiring layer having a thickness so as to restrict penetration of rays into the region irradiated. it would have been obvious to a person of ordinary skill in the art at the time the invention was made to use a metal wiring layer having a thickness so as to restrict penetration of rays into the region irradiated in Sakamoto's device in order to restrict penetration of rays into the region irradiated

10. Claims 13-14, insofar as in compliance with 35 U.S.C. 112, is rejected under 35 U.S.C. 103(a) as being unpatentable over Sakamoto in view of Takahashi (5,981,981) Sakamoto teaches substantially the entire claimed structure, as applied to claim 9 above, except using the invention in an IGBT and a MOSFET semiconductor device, wherein the impurity region is a source region. Takahashi teaches in figure 30 an IGBT and a MOSFET semiconductor device, wherein the impurity region is a source region. it

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would have been obvious to a person of ordinary skill in the art at the time the invention was made to use Sakamoto's invention in an IGBT and a MOSFET semiconductor device, wherein the impurity region is a source region in order to use the invention in an application which requires an IGBT and a MOSFET semiconductor device. The claimed limitation of a radiated region being a positive-negative junction where a parasitic diode is generated is inherent in prior art's device.

Response to Arguments

11. Applicant's arguments with respect to claims 9-14 have been considered but are most in view of the new ground(s) of rejection.

Papers related to this application may be submitted to Technology center (TC) 2800 by facsimile transmission. Papers should be faxed to TC 2800 via the TC 2800 Fax center located in Crystal Plaza 4, room 4-C23. The faxing of such papers must conform with the notice published in the Official Gazette, 1096 OG 30 (November 15, 1989). The Group 2811 Fax Center number is (703) 308-7722 and 308-7724. The Group 2811 Fax Center is to be used only for papers related to Group 2811 applications.

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Any inquiry concerning this communication or any earlier communication from the Examiner should be directed to *Examiner Nadav* whose telephone number is **(703) 308-8138**. The Examiner is in the Office generally between the hours of 7 AM to 4 PM (Eastern Standard Time) Monday through Friday.

Any inquiry of a general nature or relating to the status of this application should be directed to the **Technology Center Receptionists** whose telephone number is **308-0956**

O.N. April 22, 2003 ORI NADAV
PATENT EXAMINER
TECHNOLOGY CENTER 2800